

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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Applicant: Daniel Xu Et Al.

, Daniel Au Lt Al.

Serial No.: 09/976,641

Filed: October 12, 2001

For: Reducing Leakage Currents In

Memories With Phase-Change

Material

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 Group Art Unit:

2815

#21 1-6.09

Examiner:

B. Baumeister

Atty. Dkt. No.:

ITO.0504US (P12497)

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## **INFORMATION DISCLOSURE STATEMENT**

Dear Sir:

Applicant submits the references listed on the attached form PTO 1449 together with any required copies of such references.

This statement is being filed after a first Office action on the merits, but before receipt of a final Office action or a Notice of Allowance. A check for \$180 in payment of the late submission fee of §1.17(p) is enclosed. Please apply any additional charges or credits to Deposit Account No. 20-1504 (ITO.0504US).

Respectfully submitted,

Date:

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Timorby N. Zrop, Reg. No. 28,994 TROP, PRUNER & HU, P.C.

8554 Katy Freeway, Suite 100

Houston, Texas 77024

(713) 468-8880 [Phone] (713) 468-8883 [Fax]

Date of Deposit: 10-30-03

I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as **first class mail** with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA

Charne Tinton

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ATTY DOCKET NO.		SERIAL NO.		
ITO.0504US (P12497)		09/976,641		
APPLICANT(S):				
DANIEL XU AND TYLER A. LOWERY				

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October 12, 2001 2815 **U.S. PATENT DOCUMENTS** \*EXAMINER FILING DATE DOCUMENT N NAME CLASS SUBCLASS INITIAL IF APPROPRIATE A. B. C. D. FOREIGN PATENT DOCUMENTS TRANSLATION DATE CLASS SUBCLASS DOCUMENT NUMBER COUNTRY E. F. G. Н. OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.) Hwang, Y.N., Hong, J.S., Lee, S.H., Ahn, S.J., Jeong, G.T., Koh, G.H., Kim, H.J., Jeong, W.C., Lee, S.Y., Park, J.H., Ryoo, K.C., Horii, H., Ha, Y.H., Yi, J.H., Cho, W.Y., Kim, Y.T., Lee, K.H., Joo, S.H., Park, S.O., Jeong, U.I., Jeong, H.S. and Kim, Kinam, "Completely CMOS-Compatible Phase-Change Nonvolatile RAM Using NMOS Cell Transistors," presented at 2003 19th IEEE Non-Volatile Semiconductor Memory Workshop, Monterey, California, February 26-20, 2003 Ha; Y.H., Yi, J.H., Horii, H., Park, J.H., Joo, S.H., Park, S.O., Chung, U-In and Moon, J.T., "An Edge J. Contact Type Cell for Phase Change RAM Featuring Very Low Power Consumption," presented at IEEE 2003 Symposium on VLSI Technology, Kyoto, Japan, June 12-14, 2003 Hwang, Y.N., Hong, J.S., Lee, S.H., Ahn, S.J., Jeong, G.T., Koh, G.H., Oh, J.H., Kim, H.J., Jeong, W.C., K. Lee, S.Y., Park, J.H., Ryoo, K.C., Horii, H., Ha, Y.H., Yi, J.H., Cho, W:Y., Kim, Y.T., Lee, K.H., Joo, S.H., Park, S.O., Chung, U.L., Jeong, H.S. and Kim, Kinam, "Full Integration and Reliability Evaluation of Phasechange RAM Based on 0.24 mm-CMOS Technologies," presented at IEEE 2003 Symposium on VLSI Technology, Kyoto, Japan, June 12-14, 2003 Horii, H., Yi, J.H., Park, J.H., Ha, Y.H., Baek, I.G., Park, S.O., Hwang, Y.N., Lee, S.H., Kim, Y.T., Lee, L. K.H., Chung, U-In and Moon, J.T., "A Novel Cell Technology Using N-doped GeSbTe Films for Phase Change RAM," presented at IEEE 2003 Symposium on VLSI Technology, Kyoto, Japan, June 12-14, 2003 Μ. N. 0. DATE CONSIDERED **EXAMINER** 

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.